

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Reissue Application of

PAI-HSIANG KAO, et al.

Patent No. 6,023,094

Issued: February 8, 2000

For: **SEMICONDUCTOR WAFER HAVING
A BOTTOM SURFACE PROTECTIVE
COATING**

PRELIMINARY AMENDMENT

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Box Reissue
Commissioner for Patents
Washington, D.C. 20231

Sir:

Please amend the above-captioned reissue application as follows:

In the Claims

Please amend original Claim 1 as follows:

1. (Amended) A packaged integrated circuit device comprising:
a die having a plurality of electrical [contacts] contact bumps disposed on a first surface of the die; and
a protective film adhered directly to a back surface of the die, opposite the first surface, the protective film being thick enough to allow laser marking of the protective film without the laser penetrating to the die,
wherein the protective film has a thickness between about 1.5 and 5 mils.